

Appl. No.: 09/881,620
Reply to Office Action of Apr. 01, 2003

Atty Dkt:
UCF-287

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Appl. No. : 09/881,620
Applicant : Martin Richardson
Filed : 06/14/2001
Title : EUV, XUV, AND X-RAY WAVELENGTH SOURCES CREATED
FROM LASER PLASMA PRODUCED FROM LIQUID METAL
SOLUTIONS
TC/A.U. : 2882
Examiner : Courtney D. Thomas
Atty. Dkt. No. : UCF-287

Honorable Commissioner for Patents
P. O. Box 1450
Alexandria, VA 22313-1450

AMENDMENT

Sir:

In response to the office action mailed April 01, 2003, please amend the above-identified application as follows:

Amendments to the Claims are reflected in the listing of claims, which begins on page 2 of this paper.

Remarks/Arguments begin on page 12 of this paper.